

## Refine Search

### Search Results -

Terms	Documents
L3 and dopant	10

Database:

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### Search History

DATE: Saturday, June 26, 2004    [Printable Copy](#)    [Create Case](#)

<u>Set</u> <u>Name</u> side by side	<u>Query</u>	<u>Hit</u> <u>Count</u>	<u>Set</u> <u>Name</u> result set
	<i>DB=PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD; PLUR=YES; OP=ADJ</i>		
<u>L4</u>	L3 and dopant	10	<u>L4</u>
<u>L3</u>	(fluorinated carbons) same (CVD or PECVD or chemical vapor deposition)	70	<u>L3</u>
<u>L2</u>	(perfluorononane or perfluorooctane or perfluoroheptane or perfluorohexane or perfluorotetrane) same (CVD or PECVD or chemical vapor deposition)	4	<u>L2</u>
<u>L1</u>	(perfluorononane or perfluorooctane or perfluoroheptane) same (CVD or PECVD or chemical vapor deposition)	3	<u>L1</u>

END OF SEARCH HISTORY